

WHAT IS CLAIMED IS:

1. An optical glass for polarizing optical system having a photoelastic constant C in the range of -0.2 to +0.5 [10^{-8} cm²/N] with respect to a wavelength of 633 nm, the

5 optical glass having the following composition (1):

composition (1): when represented in terms of wt.% of oxides:

SiO2: 17.0 - 27.0 % (35.5 - 57.0 mol%)

Li2O + Na2O + K2O: 0.5 - 5.0 % (0.7 - 20.0 mol%)

PbO: 72.0 - 75.0 % (39.1 - 45.0 mol%)

As2O3 + Sb2O3: 0.1 - 3.0 % (0.1 - 2.0 mol%).

2. An optical glass for polarizing optical system having a photoelastic constant C in the range of -0.2 to +0.5 [10^{-8} cm²/N] with respect to a wavelength of 633 nm, the

15 optical glass having the following composition (2):

composition (2): when represented in terms of mol%:

SiO2: 40.0 - 54.0 mol%

R2O (R: alkali metal): 0.5 - 9.0 mol%

20 PbO: 43.0 - 45.5 mol%

As2O3 + Sb2O3: 0.1 - 1.5 mol%; and

the composition (2) further containing fluorine in the following range when represented in terms of mol%:

25 fluorine/oxygen (F/O) ratio: 0.1 - 18.0.

3. An optical glass for polarizing optical system

having a photoelastic constant C in the range of -0.2 to +0.5 [10^{-8} cm²/N] with respect to a wavelength of 633 nm, the optical glass having the following composition (3):

composition (3) when represented in terms of mol%:

5 SiO_2 : 40.0 - 54.0 mol%

R₂O (R: alkali metal): 0.5 - 9.0 mol%

RF: 0 - 16.0 mol%

R₂SiF₆: 0 - 3.3 mol%

PbO + PbF₂: 43.0 - 45.5 mol%

PbF₂: 0 - 10.0 mol%

As₂O₃ + Sb₂O₃: 0.1 - 1.5 mol%; and

the composition (3) further containing fluorine in the following range in terms of mol%:

fluorine/oxygen (F/O) ratio: 0.1 - 18.0.

4. A process for producing an optical glass for polarizing optical system, the process comprising:

changing the ratio of PbO in a lead-containing optical glass to control the photoelastic constant C thereof to provide an optical glass for polarizing optical system having a photoelastic constant C in the range of -0.2 to +0.5 [10^{-8} cm²/N] with respect to a wavelength of 633 nm,

the optical glass having the following composition (1):

composition (1): when represented in terms of wt.% of oxides:

SiO_2 : 17.0 - 27.0 % (35.5 - 57.0 mol%)

$\text{Li}_2\text{O} + \text{Na}_2\text{O} + \text{K}_2\text{O}$: 0.5 - 5.0 % (0.7 - 20.0 mol%)

PbO : 72.0 - 75.0 % (39.1 - 45.0 mol%)

$\text{As}_2\text{O}_3 + \text{Sb}_2\text{O}_3$: 0.1 - 3.0 % (0.1 - 2.0 mol%).

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5. A process for producing an optical glass for polarizing optical system, the process comprising:

changing the fluorine/oxygen (F/O) ratio of a fluorine-containing optical glass so as to regulate the refractive index thereof while retaining the photoelastic constant C of the optical glass in the range of substantially zero to provide an optical glass for polarizing optical system having a photoelastic constant C in the range of -0.2 to +0.5 [$10^{-8} \text{ cm}^2/\text{N}$] with respect to a wavelength of 633 nm,

the optical glass having the following composition (2):

composition (2): when represented in terms of mol%:

SiO_2 : 40.0 - 54.0 mol%

R_2O (R: alkali metal): 0.5 - 9.0 mol%

PbO : 43.0 - 45.5 mol%

$\text{As}_2\text{O}_3 + \text{Sb}_2\text{O}_3$: 0.1 - 1.5 mol%; and

the composition (2) further containing fluorine in the following range when represented in terms of mol%:

fluorine/oxygen (F/O) ratio: 0.1 - 18.0.

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6. A process for producing an optical glass for

polarizing optical system, the process comprising:

changing the fluorine/oxygen (F/O) ratio of a fluorine-containing optical glass so as to regulate the refractive index thereof while retaining the photoelastic constant C of the optical glass in the range of substantially zero to provide an optical glass for polarizing optical system having a photoelastic constant C in the range of -0.2 to +0.5 [10^{-8} cm²/N] with respect to a wavelength of 633 nm,

the optical glass having the following composition

(3):

composition (3) when represented in terms of mol%:

SiO₂: 40.0 - 54.0 mol%

R₂O (R: alkali metal): 0.5 - 9.0 mol%

RF: 0 - 16.0 mol%

R₂SiF₆: 0 - 3.3 mol%

PbO + PbF₂: 43.0 - 45.5 mol%

PbF₂: 0 - 10.0 mol%

As₂O₃ + Sb₂O₃: 0.1 - 1.5 mol%; and

the composition (3) further containing fluorine in the following range in terms of mol%:

fluorine/oxygen (F/O) ratio: 0.1 - 18.0.